

DAVID KUAN-YU LIU, Ph.D.

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PROFESSIONAL PROFILE

- Technical expert with over 20 years of industrial experience in the development of advanced CMOS devices and process technology, with special emphasis on non-volatile semiconductor memory devices and process technology, and high-voltage semiconductor devices, with additional 12 years of experience serving as expert consultant.
 - Named inventor on 99 US patents.
- Consultant and expert witness for past 15 years in semiconductor intellectual property evaluation and patent litigation, with deposition experience and successful ITC trial testifying experience.
- Successful track record in transitioning products from development phase to high-volume manufacturing phase, both as an individual contributor and as manager/director.
- Co-founder of an LLC in the development and licensing of intellectual property with emphasis on embedded flash memory technology.
- Co-founder of a semiconductor memory start-up company (Progressant Technologies, Inc.); participated in its successful sale to Synopsys, Inc.
- Fluent in Mandarin Chinese (native language) and English; over 10 years experience as real-time translator of church sermons and proficient in written translation.

EDUCATION

Stanford University, Palo Alto, California

Ph.D., Electrical Engineering (1989)

Thesis: Physics and Technology of Novel Conductivity-Modulated Power MOSFET's

M.S., Electrical Engineering (1985)

Coursework in integrated-circuit technology, semiconductor device physics, computer modeling of semiconductor devices and fabrication processes, and solid-state physics

University of California, Berkeley, California

B.S., Electrical Engineering (1983)

Certificate of Distinction (awarded annually to the top EECS graduate)

EXPERT WITNESS WORK - CASE EXPERIENCE:

Case: **Yangtze Memory Technologies Company, Ltd. vs. Micron Technology, Inc.**
Jurisdiction: Civil Action N.D. Cal, No. 3:223-cv-05792-RFL
Easter District of Texas
Work Product: Expert consulting work relating to 3D NAND Flash Memory Technology. Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration on 3 patents.
Nature of Case: Civil action and IPR.
Counsel: Retained by Orrick, Herrington & Sutcliffe (Contact: Jason Lang)
Date: 03/24 – Present

Case: **Force MOS Technology Co., Ltd. vs. Inergy Technology, Inc.**
Jurisdiction: Civil Action E.D. TX, No. 2:22-cv-00460-JRG
Easter District of Texas
Work Product: Expert consulting work relating to Vertical Trench DMOS process technology. Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration on 2 patents. Declaration for claim construction on 3 patents. ***Deposed on Claim Construction Declaration***, and ***deposed on declarations for IPR petitions***. Continuing work on claim construction and technical consulting.
Nature of Case: Civil action and IPR.
Counsel: Retained by Baker McKenzie (Contact: McKenzie Martin)
Date: 10/23 – Present

Case: **GlobalFoundries U.S. vs. International Business Machines**
Jurisdiction: 03348-KMK-AEK (S.D.N.Y. 2023)
Work Product: Expert consulting work relating to trade secrets involving advanced CMOS process and device technology (Nanosheet technology).
Nature of Case: Civil action.
Counsel: Retained by Latham & Watkins (Contact: Sami Al-Marzoog)
Date: 10/23 – Present

Case: **Element Capital. vs. Beijing BOE Display Technology Co., Ltd.**
Jurisdiction: Civil Action No. 2:22-cv-00118-JRG
Eastern District of Texas
Work Product: Expert consulting work relating to OLED technology. Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration on 3 patents.
Nature of Case: Civil action.
Counsel: Retained by Fish & Richardson (Contact: Linhong Zhang)
Date: 4/23 – 12/23

Case: **Sonrai Memory Ltd. vs. Micron Technology, Inc.,**
Jurisdiction: Civil Action No. 6:22-cv-000855-FB
Western District of Texas
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration resulting in institution of the petition and ***deposed on supplemental declaration.***
Nature of Case: Civil action.
Counsel: Retained by Fish & Richardson (Contact: Tim Riffe)
Date: 12/22 – Present

Case: **Daedalus Prime LLC vs. Samsung Electronics Co.,**
Jurisdiction: Civil Action E.D. TX, Marshall Div., No. 2:22-cv-353
Eastern District of Texas, Marshall Div., and
Investigation No. 337-TA-1336
Work Product: Expert consulting work relating to FINFET process technology. Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration on 2 patents. Source code database viewing (GDS layout and process flow documents) for supporting of non-infringement position.
Nature of Case: Civil action and ITC Investigation on Certain Semiconductor Devices, Mobile Devices Containing the Same and Components Thereof..
Counsel: Retained by Fish & Richardson (Contact: Kevin Su)
Date: 10/22 – 4/23

Case: **Netlist, Inc. vs. Samsung Electronics Co. Ltd. et al.,**
Jurisdiction: Civil Action No. 2:21-cv-00463
Eastern District of Texas
Work Product: Expert consulting work relating to memory modules.
Nature of Case: Civil action.
Counsel: Retained by Fish & Richardson (Contact: Tony Nguyen)
Date: 8/22 – 12/22

Case: **Vervain, LLC vs. Micron Technology & related IPR Petition**
Jurisdiction: Action No. 6:21-cv-00487-ADA
Western District of Texas
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration on 4 patents, all 4 petitions instituted, and ***deposed on both initial declaration and reply declaration on all 4 patents.***
Counsel: Retained by Orrick, Herrington & Sutcliffe LLP (Contact: Jared Bobrow)
Date: 8/21 – 2/23

Case: **Monterey Research vs. Qualcomm PTAB Matter**
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration.
Counsel: Retained by Jones Day (Contact: David Cochran)
Date: 12/21 – Current

Case: **Semiconductor Energy Laboratory Co., OLED Patent Matters**
Jurisdiction: Action No. 8:21-cv-00554-JAK-ADS
Central District of California
Work Product: Expert for infringement on 3 patents relating to OLED driver circuit and layout, responsibilities include source code viewing, GDS layers viewing, and claim charts review.
Nature of Case: Civil action.
Counsel: Retained by Fish & Richardson (Contact: Bryan Basso)
Date: 9/21 – 4/22

Case: **Apple Inc. IPR Petition for U.S. Patents 6,622,108 & 6,807,505**
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration.
Counsel: Retained by Erise IP (Contact: Paul Hart)
Date: 8/21 – 9/21

Case: **Texas Instruments IPR Petition**
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration.
Counsel: Retained by Fish & Richardson (Contact: Josh Griswold)
Date: 9/20 – 4/21

Case: ***Micron Technology vs. UMC/JinHua***
Jurisdiction: Case No. 4:17-CV-06932-MMC
United States District Court for the Northern District of California
Work Product: Testifying expert, trade secret documents review, and declaration submission.
Nature of Case: Trade secret contention of Micron confidential documents.
Counsel: Retained by Jones Day (Contact: Randy Kay)
Date: 3/17 – 12/23

Case: ***SK Hynix vs. BitMicro***
Jurisdiction: Investigation No. 337-TA-1097
United States International Trade Commission
Work Product: Testifying expert for non-infringement on 2 patents, issued expert rebuttal report, ***deposition taken***, issued witness statement.
Nature of Case: ITC infringement case concerning module stacking of SDRAM.
Counsel: Retained by Fish Richardson (Contact: Joseph Colaanni)
Date: 11/18 – 4/19

Case: ***Rohm Company IPR Petition***
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration.
Counsel: Retained by Fish & Richardson (Contact: Matt Colvin)
Date: 4/18 – 8/18

Case: ***Apple Inc., vs. Qualcomm Incorporated***
Jurisdiction: Case No. 3:17-CV-02402
United States District Court for the Southern District of California
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration, ***2 depositions taken***.
Counsel: Fish & Richardson (Contact: Tony Nguyen)
Date: 1/18 – 5/19

Case: ***Macronix vs. Toshiba***
Jurisdiction: Investigation No. 337-TA-1046
United States International Trade Commission
Work Product: Testifying expert for infringement and non-invalidity on 2 patents, claim construction analysis, technical tutorial, database viewing for evidence gathering, issuing expert report and expert rebuttal report, ***deposition taken for 2 patents***, issued witness statement and rebuttal witness statement, ***testified in ITC court on both infringement and invalidity***.
Nature of Case: ITC infringement case concerning advanced NAND Flash memory.
Counsel: Retained by Fish Richardson (Contact: David Barken)
Date: 4/17 – 10/18

Case: ***Novatek Microelectronics Corp. IPR Petition***
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration.
Counsel: Retained by Kroub, Silbersher & Kolmykov PLLC (Contact: Sergey Kolmykov)
Date: 2/17 – 4/17

Case: ***Taiwan Semiconductor Manufacturing Company IPR Petition***
Work Product: Patent analysis and prior art review toward preparation of IPR petition material and draft of declaration.
Counsel: Retained by Fish & Richardson (Contact: John Goetz)
Date: 7/15 – 4/17

Case: ***Triune Systems, LLC vs. Wayne Chen, et al.,***
Jurisdiction: Case No. 296-03209-2013,
District Court of Collin County, TX
Work Product: Testifying expert, database viewing, expert report, ***video-taped testimony***
Nature of Case: Defending against trade secret contention.
Counsel: Retained by Gordon & Rees LLP (Contact: Robert Bragalone)
Date: 5/15 – 9/15

Case: ***Macronix vs. Spansion***
Jurisdiction: Investigation No. 337-TA-922
United States International Trade Commission
Work Product: Testifying expert, claim construction analysis, technical tutorial, database viewing for evidence gathering, expert report, expert rebuttal report.
Nature of Case: ITC infringement case concerning Flash memory cell
Counsel: Retained by Fish Richardson (Contact: David Barken)
Date: 9/14 – 1/15

Case: ***Macronix vs. Spansion***
Jurisdiction: Investigation No. 337-TA-909
United States International Trade Commission
Work Product: Database viewing for evidence gathering, support technical content of expert report, support technical content against rebuttal report.
Nature of Case: ITC infringement case concerning Flash memory cell
Counsel: Retained by Winston & Strawn (Contact Michael Murray)
Date: 5/14 – 1/15

Case: ***Keranos, LLC v. Analog Devices et. al.***
Jurisdiction: Civil Case No. 2:10-CV-00207
United States District Court for the Eastern District of Texas
Work Product: Claim Chart Generation and Claim Construction
Nature of Case: Patent infringement case concerning split gate Flash memory cell
Counsel: Retained by Agility IP (Contact Michelle Breit)
Date: 2/09 – 2/14

Case: ***Silicon Storage Technology, Inc. v. Xicor, LLC***
Jurisdiction: Civil Case No. CV 10-01515
United States District Court for the Northern District of California
Work Product: Expert report and declarations
Nature of Case: Matter concerning United States Reissue Patent RE38,370 on the process of flash memory cell.
Counsel: Retained by Shore Chan Bragalone LLP (Contact Patrick Conroy)
Date: 6/11 – 10/11

Case: ***Fast Memory Erase, LLC v. Spansion et.al.***
Jurisdiction: Civil Case No. 3:10CV-481
United States District Court for the Northern District of Texas
Work Product: Declarations
Nature of Case: Defending Motion for Attorney Fees.
Counsel: Retained by Shore Chan Bragalone LLP (Contact Patrick Conroy)
Date: 2/10 – 6/10

Case: ***Fast Memory Erase, LLC v. Spansion et.al.***
Jurisdiction: Civil Case No. 3-08cv0977M
United States District Court for the Northern District of Texas
Work Product: Testifying expert: issuing expert report, declarations, and ***deposition taken.***
Nature of Case: Patent infringement case concerning minimizing source current during erase of Flash memory cell.
Counsel: Retained by Shore Chan Bragalone LLP (Contact Patrick Conroy)
Date: 2/09 – 5/10

PROFESSIONAL EXPERIENCE:

10/07 to present: **Technical Consultant/Expert Witness**

Serving as a technical consultant and advisor in the area of semiconductor device and process technologies. Expert witness in ITC cases and district court cases, with successful testifying experience in trial hearing. Depositions taken at least 6 times for both litigation cases and IPR petitions. Experienced in source code viewings of circuit schematics and GDS layouts; seasoned in reverse engineering of integrated circuits, as well as techniques for de-processing and analyzing semiconductor chips. Responsibilities including gathering and reviewing of evidence, issuing declaration on claim construction, giving technical tutorial, issuing expert report and expert rebuttal report. Technical consultant for evaluating numerous flash memory and CMOS image sensor patent portfolios for licensing and acquisition consideration. Assessed qualitative merits of each patent portfolio and identified potential infringers and potential licensees. Generated numerous claim charts against potential infringers based on published patents, technical papers and datasheets, and reverse engineering reports.

10/07 to 4/11: **Jonker, LLC**

Inventor and Partner. Developed an intellectual property (IP) portfolio (7 U.S. patents granted and 3 U.S. patent applications pending) on zero-cost CMOS-logic-compatible embedded flash memory. Successfully negotiated the acquisition of this IP portfolio by a major semiconductor company.

8/04 to 10/07: **Maxim Integrated Products, San Jose, California**

Senior Scientist. Responsible for developing embedded non-volatile memory process technology for battery management products. Duties included supervising the development of integrated process flows at the 0.35 μ m and 0.18 μ m CMOS technology nodes. Analyzed and solved process-related reliability issues.

5/00 to 8/04: **Xilinx, Incorporated, San Jose, California**

Senior Manager. Responsible for developing non-volatile memory process technology for flash and CPLD products, as well as advanced CMOS process technology (75nm node). Duties included supervising the development of integrated non-volatile memory process flows at multiple CMOS technology nodes to meet product application requirements. Analyzed and solved process-related reliability issues.

2/00 to 5/00 **Progressant Technologies, Fremont, California**

Co-Founder. Facilitated IP development and sale of the company to Synopsys, Inc.

9/98 to 2/00

Programmable Silicon Solutions, Sunnyvale, California

Director of Process Engineering. Responsible for developing a fully logic compatible embedded flash memory technology for WSMC (a semiconductor foundry). Developed a new integrated process flow to implement a proprietary flash cell in a high-performance logic process, supervised testchip and product tapeout, process optimization, device optimization, and product yield enhancement. Applied interpersonal skills to align the goals of the foundry technology development group to that of PSS. Participated in the strategic planning of a technology roadmap and foundry strategy for the company.

9/97 to 9/98

AMIC Technology, Santa Clara, California

Director of Flash Technology. Responsible for developing 0.35μm ETOX-based flash memory technology. Prepared the business plan and technology roadmap. Developed a new integrated process flow, supervised testchip and product tapeout, process optimization, device optimization, and product yield enhancement.

5/96 to 9/97

Altera Corp., San Jose, California

Device Engineering Manager. Responsible for technology development, process integration, and foundry interface for 0.35μm generation of logic and EEPROM programmable logic device technology. Duties included project schedule planning, supervision of testchip and product tapeout, process optimization, and product yield enhancement.

7/95 to 5/96

Information Storage Devices, San Jose, California

Technology Development Manager/Program Manager. Led a project team of 10 in technology development, process integration, and first product introduction, with a new foundry. Duties included project schedule planning, supervision of testchip and product tapeout, process optimization, resolution of sorting issues and yield enhancement.

5/92 to 7/95

Advanced Micro Devices, Sunnyvale, California

Member of Technical Staff. Led the development of low-energy/DINOR-type flash EPROM technology. Key individual contributor in optimizing the process and design of flash cell and periphery devices in AMD's 0.5μm and 0.35μm flash EPROM technologies. Duties included process integration, device modeling, and development of triple-well technology and high-voltage transistors for negative gate erase operation.

1/89 to 4/92

Texas Instruments, Dallas, Texas

Member of Technical Staff. Research and development of 16Mb generation of flash EPROM technology, as well as a new generation of antifuse-based FPGAs. Duties included process integration, device modeling, high-voltage CMOS process integration, and investigation of a novel source-side injection mechanism for EPROM channel hot-electron programming.

AWARDS/HONORS

U.C. Berkeley Certificate of Distinction Award, 1983

AEA Faculty Development Fellowship, 1983-1985

AMD Spotlight Award, 1995

PATENTS

1. U.S. Patent 5,106,773, "Programmable Gate Array and Methods for Its Fabrication" (with K.-L. Chen and H. Tigelaar), issued April 21, 1992.
2. U.S. Patent 5,166,557, "Gate Array with Built-in Programmable Circuitry" (with K.-L. Chen), issued November 24, 1992.
3. U.S. Patent 5,202,576, "Asymmetrical Non-Volatile Memory Cell, Arrays, and Methods for Fabricating the Same" (with M. Wong), issued April 13, 1993.
4. U.S. Patent 5,219,782, "Sublithographic Antifuse and method for Manufacturing" (with K.-L. Chen), issued June 15, 1993.
5. U.S. Patent 5,250,464, "Method of Making a Low Capacitance, Low Resistance Sidewall Antifuse Structure" (with M. Wong), issued October 5, 1993.
6. U.S. Patent 5,264,384, "Method of Making a Non-Volatile Memory Cell" (with C. Kaya), issued November 23, 1993.
7. U.S. Patent 5,300,803, "Source Side Injection Non-volatile Memory Cell," issued April 5, 1994.
8. U.S. Patent 5,365,105, "Sidewall Antifuse Structure and Method for Making," issued November 15, 1994.
9. U.S. Patent 5,371,402, "Low Capacitance, Low Resistance Sidewall Antifuse Structure and Process" (with M. Wong), issued December, 1994
10. U.S. Patent 5,395,797, "Antifuse Structure and Method of Fabrication," issued March 7, 1995.
11. U.S. Patent 5,470,773, "Method of Protecting a Stacked Gate Edge in a Semiconductor Device from Self Aligned Source (SAS) Etch" (with Y. Sun and C. Chang), issued November 28, 1995.
12. U.S. Patent 5,482,880, "Non-Volatile Memory and Fabrication Method," (with C. Kaya), issued January 9 1996.
13. U.S. Patent 5,517,443, "Method and System for Protecting a Stacked Gate Edge in a Semiconductor Device from Self Aligned Source (SAS) Etch in a Semiconductor Device," issued May 14, 1996.
14. U.S. Patent 5,521,867, "Adjustable Threshold Voltage Conversion Circuit" (with Jian Chen), issued May 28, 1996.
15. U.S. Patent 5,534,455, "Method and System for Protecting a Stacked Gate Edge in a Semiconductor Device from Self Aligned Source (SAS) Etch in a Semiconductor Device," issued July 9, 1996.

16. U.S. Patent 5,541,875, "High Energy Buried Layer Implant To Provide A Low Resistance P-Well in A Flash EPROM Array" (with Jian Chen), issued May 28, 1996.
17. U.S. Patent 5,590,076, "Channel Hot-Carrier Page Write," issued December 31, 1996.
18. U.S. Patent 5,596,531, "Method for Decreasing the Discharge Time of A Flash Memory Cell," issued January 21, 1997.
19. U.S. Patent 5,612,914, "Asymmetrical Non-volatile Memory Cell, Arrays and Methods for Fabricating Same" (with Man Wong), issued May 18, 1997.
20. U.S. Patent 5,624,859, "Method for Providing Device Isolation and Off-State Leakage Current for a Semiconductor Device," issued April 29, 1997.
21. U.S. Patent 5,625,220, "Sublithographic Antifuse," (with K.L. Chen), issued April 29, 1997.
22. U.S. Patent 5,646,430, "Non-volatile Memory Cell Having Lightly-Doped Source Region" (with C. Kaya), Issued July 8, 1997.
23. U.S. Patent 5,650,964, "Method of Inhibiting Degradation of Ultra Short Channel Charge-carrying Devices during Discharge," (with Jian Chen), Issued July 22, 1997.
24. U.S. Patent 5,652,155, "Method for Making Semiconductor circuit Including Non-ESD Transistors with Reduced Degradation Due to an Impurity Implant," Issued July 27, 1997.
25. U.S. Patent 5,656,509, "Method and Test Structure for Determining Gouging in a Flash EPROM Cell During SAS Etch," Issued July 29, 1997
26. U.S. Patent 5,661,059, "Boron Penetration to Suppress Short Channel Effect in P-channel Device," Issued August 26, 1997.
27. U.S. Patent 5,674,764, "Method of Making Asymmetrical Non-volatile Memory Cell," Issued October 7, 1997.
28. U.S. Patent 5,693,972, "Method and System for Protecting a Stacked Gate Edge in a Semiconductor Device from Self-Aligned Source (SAS) Etch in a Semiconductor Device," Issued December 2, 1997.
29. U.S. Patent 5,751,631, "Flash memory cell and a new method for sensing the content of the new memory cell," Issued May 12, 1998
30. U.S. Patent 5,789,295, "Method of Eliminating or Reducing Poly1 Oxidation at Stacked Gate Edge in Flash EPROM Process," Issued August 4, 1998.
31. U.S. Patent 5,814,854, "Highly scalable FLASH EEPROM cell," Issued September 29, 1998.
32. U.S. Patent 5,814,864, "Semiconductor Circuit Including Non-ESD Transistors with Reduced Degradation Due to an Impurity Implant," Issued September 29, 1998.

33. U.S. Patent 5,912,836, "Circuit for Detecting Both Charge Gain and Charge Loss Properties in a Non-Volatile Memory Array," Issued June 15, 1999.
34. U.S. Patent 5,930,174, "Circuit and Method for Erasing Flash Memory Array," Issued July 27, 1999.
35. U.S. Patent 5,981,994, "Method and Semiconductor circuit for Maintaining Integrity of Field Threshold Voltage Requirements," Issued November 9, 1999.
36. U.S. Patent 5,995,418, "Circuit and Method for Erasing Flash Memory Array," Issued November 30, 1999.
37. U.S. Patent 6,026,017, "Compact nonvolatile memory," Issued February 15, 2000.
38. U.S. Patent 6,027,974, "Nonvolatile memory," Issued February 22, 2000.
39. U.S. Patent 6,088,263, "Non-volatile memory using substrate electrons," Issued July 11, 2000.
40. U.S. Patent 6,091,636, "Flash memory cell and a new method for sensing the content of the new memory cell," Issued July 18, 2000.
41. U.S. Patent 6,127,225, "Memory cell having implanted region formed between select and sense transistors," Issued October 3, 2000.
42. U.S. Patent 6,159,800, "Method of forming memory cell," Issued December 12, 2000.
43. U.S. Patent 6,188,604, "Flash memory cell & array with improved pre-program and erase characteristics," Issued February 13, 2001.
44. U.S. Patent 6,185,133, "Flash EPROM using junction hot hole injection for erase," Issued February 6, 2001.
45. U.S. Patent 6,252,799, "Device with embedded Flash and EERPOM memories," Issued June 26, 2001.
46. U.S. Patent 6,326,265, "Device with Embedded Flash and EPROM Memories," Issued December 4, 2001.
47. U.S. Patent 6,417,550, "High voltage MOS devices with high gated-diode breakdown voltage and punch-through voltage," Issued July 9, 2002.
48. U.S. Patent 6,479,862, "Charge trapping device and method for implementing a transistor having a negative differential resistance mode," Issued November 12, 2002.
49. U.S. Patent 6,512,274, "CMOS-process compatible, tunable NDR (negative differential resistance) device and method of operating same," Issued January 28, 2003.
50. U.S. Patent 6,596,617, "CMOS compatible process for making a tunable negative differential resistance (NDR) device," Issued July 22, 2003.

51. U.S. Patent 6,624,026, "Nonvolatile Memory," Issued September 23, 2003.
52. U.S. Patent 6,680,245, "Method for making both a negative differential resistance (NDR) device and a non-NDR device using a common MOS process," Issued January 20, 2004.
53. U.S. Patent 6,686,631, "Negative differential resistance (NDR) device and method of operating same," Issued February 3, 2004.
54. U.S. Patent 6,693,027, "Method for configuring a device to include a negative differential resistance (NDR) characteristic," Issued February 17, 2004.
55. U.S. Patent 6,700,155, "Charge trapping device and method for implementing a transistor having a configurable threshold," Issued March 2, 2004.
56. U.S. Patent 6,711,063, "EEPROM memory cell array architecture for substantially eliminating leakage," Issued March 23, 2004.
57. U.S. Patent 6,835,979, "Nonvolatile Memory," Issued December 28, 2004.
58. U.S. Patent 6,969,894, "Variable threshold semiconductor device and method of operating same," Issued November 29, 2005.
59. U.S. Patent 6,972,234, "High Voltage MOS Devices with High Gated-Diode Breakdown Voltage and Punch-through Voltage," Issued December 6, 2005.
60. U.S. Patent 6,972,465, "CMOS process compatible, tunable negative differential resistance (NDR) device and method of operating same," Issued December 6, 2005.
61. U.S. Patent 7,067,873, "Charge Trapping Device," Issued June 27, 2006.
62. U.S. Patent 7,091,077, "Method of directionally trimming polysilicon width," Issued August 15, 2006.
63. U.S. Patent 7,109,078, "CMOS compatible process for making a charge trapping device," Issued September 19, 2006.
64. U.S. Patent 7,301,194, "Shrinkable and highly coupled double poly EEPROM with Inverter," Issued November 27, 2007.
65. U.S. Patent 7,436,710, "EEPROM memory device with cell having NMOS in a P pocket as a control gate, PMOS program/erase transistor, and PMOS access transistor in a common well," Issued October 14, 2008.
66. U.S. Patent 7,535,758, "One or Multiple-Times Programming Device," Issued May 19, 2009.
67. U.S. Patent 7,782,668, "Integrated circuit embedded with Non-volatile One-Time-Programmable and Multiple-Time Programmable memory," Issued August 24, 2010.

68. U.S. Patent 7,787,295, "Integrated circuit embedded with Non-volatile Multiple-Time Programmable memory having variable coupling," Issued August 31, 2010.
69. U.S. Patent 7,787,304, "Method of making integrated circuit embedded with Non-volatile One-Time-Programmable and Multiple-Time Programmable memory," Issued August 31, 2010
70. U.S. Patent 7,787,309, "Method of operating integrated circuit embedded with Non-volatile One-Time Programmable and Multiple-Time Programmable memory," Issued August 31, 2010.
71. U.S. Patent 7,791,955, "Method of erasing a block of memory cells," Issued September 7, 2010.
72. U.S. Patent 7,835,184, "EEPROM memory cell with first-dopant-type control gate transistor, and second-dopant type program/erase and access transistors formed in common well," Issued November 16, 2010
73. U.S. Patent 7,835,186, "Method of programming a selected memory cell," Issued November 16, 2010.
74. U.S. Patent 7,852,672, "Integrated Circuit embedded with Non-Volatile programmable memory having variable coupling," Issued December 14, 2010
75. U.S. Patent 7,876,615, "Method of operating integrated circuit embedded with Non-Volatile programmable memory having variable coupling related application data," Issued January 25, 2011
76. U.S. Patent 7,920,426, "Non-volatile memory programmable through areal capacitive coupling," Issued April 5, 2011
77. U.S. Patent 7,944,750, "Multi-programmable Non-Volatile Memory Cell," Issued May 17, 2011
78. U.S. Patent 8,203,861, "Non-Volatile One-Time Programmable and Multiple-Time Programmable Device," Issued June 19, 2012
79. U.S. Patent 8,208,299, "Integrated Circuit Embedded with Non-Volatile Programmable Memory Having Variable Coupling and Separate Read/Write Paths," Issued June 26, 2012
80. U.S. Patent 8,300,470, "Two Terminal Programmable Hot Channel Electron Non-Volatile Memory," Issued October 30, 2012
81. U.S. Patent 8,305,805, "Common Drain Non-Volatile Multiple-Time Programmable Memory," Issued November 6, 2012
82. U.S. Patent 8,325,519, "Method of Operating Integrated Circuit Embedded with Non-Volatile Programmable Memory having Variable Coupling Ratio," Issued December 4, 2012.

83. U.S. Patent 8,580,622, "Method of Making Integrated Circuit Embedded with Non-Volatile Programmable Memory having Variable Coupling," Issued November 12, 2013.
84. U.S. Patent 8,582,342, "Non-Volatile One-Time-Programmable and Multiple-Time Programmable Memory Configuration Circuit," Issued November 12, 2013.
85. U.S. Patent 8,599,612, "Method of Operating Integrated Circuit Embedded with Non-Volatile Programmable Memory having Variable Coupling Related Application data," Issued December 3, 2013.
86. U.S. Patent 8,705,263, "Non-Volatile One-Time-Programmable and Multiple-Time Programmable Memory Configuration Circuit," Issued April 22, 2014.
87. U.S. Patent 8,988,103, "Capacitively Coupled Logic Gate," Issued March 24, 2015.
88. U.S. Patent 9,064,192, "Automatic Valid Vote Count Storage using Secure Embedded Non-Volatile Memory," Issued June 23, 2015.
89. U.S. Patent 9,224,739, "Method of Making Integrated Circuit Embedded with Non-Volatile Programmable Memory having Variable Coupling," Issued December 29, 2015.
90. U.S. Patent 9,305,931, "Zero Cost NVM Cell Using High Voltage Devices in Analog Process," Issued April 5, 2016.
91. U.S. Patent 9,324,438, "Method of Operating Incrementally Programmable Non-Volatile Memory," Issued April 26, 2016.
92. U.S. Patent 9,558,813, "Method of Operating Incrementally Programmable Non-Volatile Memory," Issued January 31, 2017.
93. U.S. Patent 9,570,161, "Method of Operating Incrementally Programmable Non-Volatile Memory," Issued February 14, 2017.
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